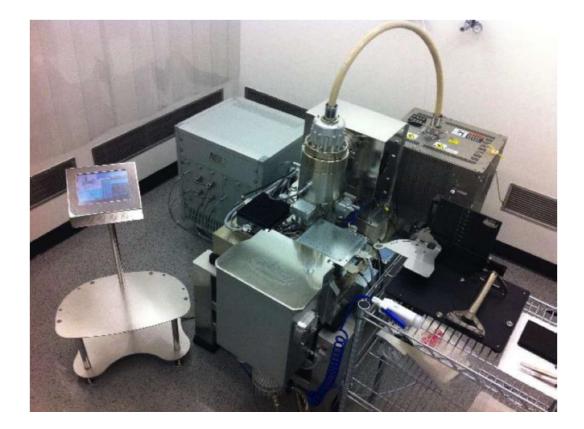


NanoBeam nB4 Standard Operating Procedure

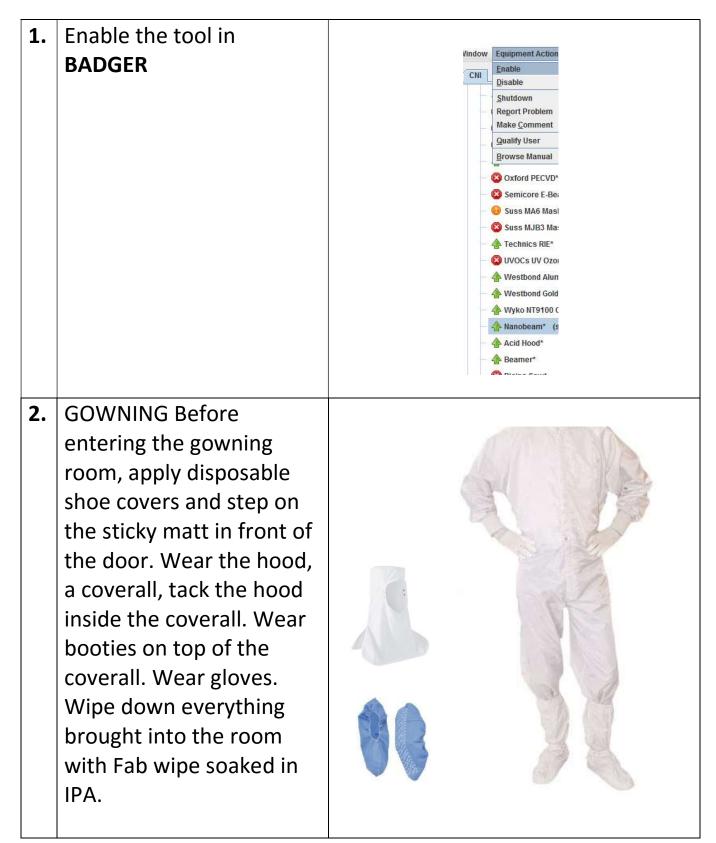
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These instructions are intended for reference only, and will *not* replace the thorough training required for proper system operation. Contact a clean room staff member with questions or to report a system problem. This documents is based on operating instructions written by Sunwoo Lee and Diego Scarabelli.











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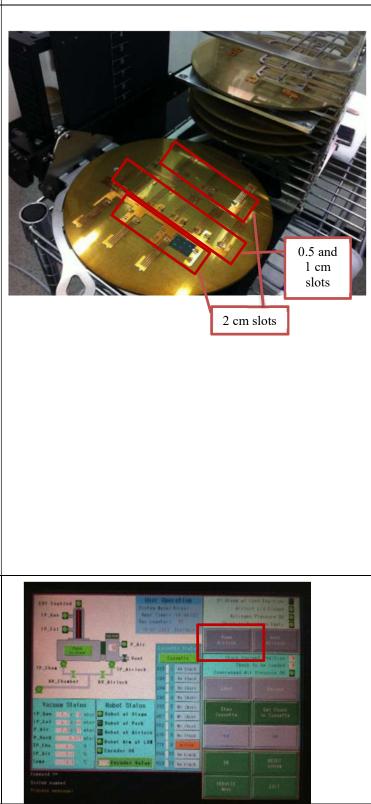
3.	CURRENT MEASUREMENT: Type "stage fc" in the terminal (moves the stage to the Faraday cage for current measurement). and open the current meter ("A"). Value should be 0.5-70 nA.	NanoBeam Lithography Software on nbserver017 N I N I No I N I N I N I N I N I N I N
4.	UNLOAD CHUCK and TEMP CHECK: Unload the loaded chuck by clicking "Unload". Return the stage to the load position by typing "stage load" in the terminal. Verify by going to stage control (green square icon"). Check the room temperature ("Pa"). Should be around 19 °C.	NanoBeam Lthography Solution on nbserver017 Image: Solution of the server017 Image: Solution of the server017 </th
5.	VENT: enter the inner room (make sure door closes behind you) and vent the Air lock by pressing "VENT AIRLOCK" on the PLC (should be green) and confirm with "OK" (takes ~7min). An "Air lock vented" message will appear on the bottom left corner of the screen.	Image: State in the state





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LOAD SAMPLE: Carefully (two 6. hands) lift the lid and open load lock. Take out the tray (handle should be on the left side) and load your sample. Lift the tray and place it on the table, plugging the three pins at the bottom in the three holes on the stage (small handle-lock facing you). Close the lid. Extract the desired chuck from the tray (do not use cuck #11). Load your sample in the appropriate space to its dimensions. No pressure should be put on the lid while loading your sample. Sample inserted into the Nanobeam should have a clean backside and should be prebaked for minimization of outgassing. Chuck #9 is recommended (with six 2 cm-slots, three 1 cm-slots, and three 0.5 cm-slots).Two tweezers may be of use when loading the sample. 7. PUMP AIR LOCK: Reposition the chuck in the tray, open the lid and place the tray inside the airlock (make sure to insert the three pins inside their respective holes). Remove the handle and close the lid. Pump the load lock by clicking "Pump Air Lock" on PLC and confirm by "OK".







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Wait in the room until TP air steadily increases and you hear the sound of the turbo pump increasing in pitch. If the turbo fails to activate (TP air will not increase or PLC pump button turn green again) click on "RESET", "PUMP DOWN" and "OK".	Bart Tanabad Bart Streak Jamil F. Samabad Bart Streak Jamil F. Jamil F. Jamil
8. Wait until the pressure appears and decreases to < 1.9x10 ⁻⁶ mbar (10-20 minutes usually). LOAD CHUCK: go back to the control room. Choose the "CHUCK CONTROL" menu, choose the chuck that contains your sample and click on "LOAD".	Position Occupied Label Loaded Position Occupied Label Loaded Council Counci

9.	ADJUST STEP HEIGHT: if you're using a sample 500 μm thick (standard 4" waters) skip to step 10. The stage has a built-in metal block for height adjustments, called "datumstep", in steps of 110 μm each. Datum 1 is for thickest sample and 11 the thinnest. Systate files may have a different datumstep corresponding calibration. Contact superusers for more information.	Image: Second
10.	SET BEAM CURRENT: In the terminal, press the button "Restore DB" and then type the number correspondent to the database file you intend to load.	RanoBeam Terminal 11.01 on nbserver017 Fle Edit History Hei Connecting to "nbserver017" Done. So run restore_db • log_file : machine: edl7 (2016-03-29 00:45:20) Current c-beam conditions: DE loaded: No Select a DB to restore: No Select a DB to restore: No Select a DB to restore: No Select a DB to restore: No Select a DB to restore: No Select a DB to restore: No Select a DB to restore: No Select a DB to restore: No Select a DB to restore: No Select a DB to restore: No Select a DB to restore: Row cabe/adums_16y093m19_1520.nrf> Se
11.	Click the C (Auto Conjugate) button in the terminal to run a calibration sequence – DO NOT run this until the system has reached the base pressure of 1.9x10 ⁻⁶ mbar.	NanoBe im Terminal 01.01 on nbserver017 File Edit Ristory Help





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12. LOCATE ALINGMENT MARKS: From the main tool bar click on 🔪 (=) 🕼 🔅 🛄 🔝 🔍 == 📑 🕥 💿 💷 🚺 🅼 🏌 🌆 "Position Database" to open the position database window. 40298 71.085441 💽 🔚 Select the location of the 340298 71.085441 💽 🔓 bottom-left corner of the chip 7 786964 63 003991 82.847021 63.046536 (from your stored in folder information) and press the 69 085441 86.820582 67.98165 32.321102 68.01915 yellow arrow to move the stage 32 61.980609 82.764332 62.01915 💽 📔 to that position. You can also 89.193849 62.133392 🔽 🔚 /9.425619 62.1229/5 💽 듺 move the stage directly by pressing the "Stage Control" button. To move by Step Size _ 🗆 × y Soft Fire on nbserver017 🔪 🍺 🛄 🛞 🍈 🛄 🐏 🔍 🗰 🗱 🔳 🕲 🚱 🛶 🚺 👍 🏌 press blue arrow, to move by Step Size times Multiplier, press Stage Control on nbserver017 - 🗆 × the red arrows. Step Size: 100 um Stage Position X: 5.227341 Y: 28.002136 mm **13.** Click on "SEM View" to observe the sample and actual alignment 🔪 📁 🛄 🔿 🌔 L 🗢 🛃 🔳 🕲 💿 💴 🚺 🏌 marks present on it. Note that the top right corner of the chip The Ven Mah Red 🕑 rormal 🕑 [20 🖬 🍋 🖖 🚥 🔛 🔪 🔍 🔍 + 20.r when loading, will appear in the SEM as bottom left corner (the prospective is rotated by 180°). Contrast and brightness can be adjusted by clicking on "auto brightness". It's recommended to turn the SEM off when moving stage to minimize beam 🛲 🔪 🍺 🖽 🔿 🌾 🛄 🛄 🍳 🥌 📑 🕲 🚱 🛶 🚺 🎄 🏌 exposure of your sample.





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14.	pressing CTRL + mouse left click in the SEM view in correspondence with the center of your mark. To save a new position in the database, press on green "V" button (top left corner of the position database window), insert a name, click on the "camera" icon to acquire position and "save" icon to save it.	Name Y Main Kana Kana<
15.	SEMIM-AUTOMATIC FOCUSING PROCEDURE is performed by typing in the terminal "af [markname]" to autofocus on the mark. You can check the procedure configuration clicking "Mark Type Database" from the main tool bar and choosing the name correspondent to the alignment mark utilized. This method is an alternative to the fully auto procedure (registration).	Image: Intervent of the second of the sec



16.	MANUAL FOCUSING can also be performed using the focus control available in the main tool bar. Multipliers at the top allow different focus adjustment finesse. You need at least three alignment marks. Store them in the position database then type "stage load" in the terminal to return to the home position.	Image: A lithography Software on abserver017 Image: A lithography Software on abserve
17.	OPEN JOB FILE. Click on the "J" icon in the main tool bar and select the file from your folder (with a ".njf" format). The job file uses patterns files with ".npf" format which should be saved under: Server/patterns/[yourname], accessible by clicking on the "P" icon in the main tool bar. Double check: marks names, block origins and pattern file names. Go to step 22 to learn how to create a job file.	Image: Section Database on hoserver017



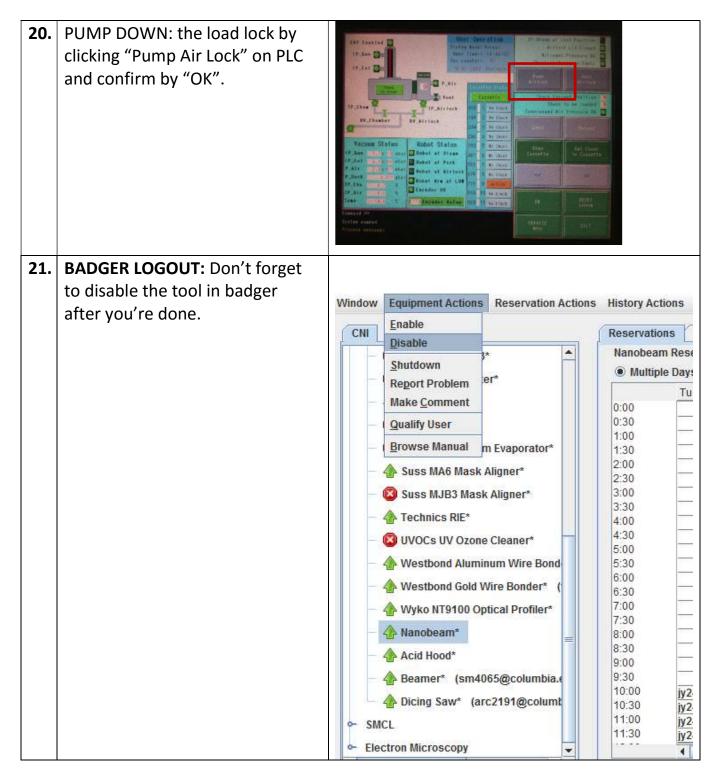


18.	RUN JOB: copy and paste the	NanoBeam Terminal 01.01 on nbserver017 File Edit History Help	×
	first line of the job into the	🔀 🕑 🏥 💾 💽 Go	
	terminal and press "enter" to run the job. The machine is	starting time: 08:37:06-2016_Mar_29 finishing time: 08:39:01-2016_Mar_29 total duration: 115 (s)	
	reading the instructions present in your job file. Check for any mistake or error that could potentially show up. If everything is correct, confirm typing "2" and press enter.	auto_conjugate> \$> run nbwrite digg/AG/AG-dosetest.njf -1=diego:onecm_top_mark22 # machine: eDi7 (2016-03-29 09:06:27) load jobfiles setup position and beam for writing check dose and pattern nbwrite (AG-dosetest.njf) - 09:06:40 29-03-2016 #lohal cettings NanoBeam Terminal 01:01 on mbserver017 File Edit History Help ManoBeam Terminal 01:01 on mbserver017 File Edit History Help Manual deflection corrections: mf_trim: 1.0 1.0 0.0 0.0 sf_trim: 1.0 1.0 0.0 0.0 sf_trim: 1.0 1.0 0.0 0.0 File Edit History Help Manual deflection corrections: mf_trim: 1.0 1.0 0.0 0.0 sf_trim: 1.0 1.0 0.0 0.0 Comparison failed cells and write successful ones 2 All cells - skip registration failed cells and write successful ones 2 All cells - skip admarks and write all cells incl failed ones (-r) 3 Global run - perform global registration only 4 Test run - global and local registration to whole block (-s) 5 ist local - epply 1st local registration to whole block (-s)	
10	LUCADING After the ich is	nbwrite> 2	
19.	ULOADING. After the job is	,	
	done, unload your chuck using	ManoBeam Lithography Software on nbserver017	_ 🗆 🗙
	the "chuck control" window:	i 🔤 🔪 🗐 🧶 📜 🛄 🔍 🔷 🐺 🔳 🕲 ତ 🚄 頂 🗄 🏌	
	Unload the loaded chuck by		
	clicking "Unload". Return the	Chack Control on Inserver017 Position Occupied Label Loaded	
	stage to the load position by		
	typing "stage load" in the	3	
	terminal. Verify by going to		
	stage control (green square		
	icon"). Vent (by pressing "Vent	7 🗖 🥵 📖	
	Airlock") in the PLC, unload the	a Urisad	
	sample. Try to coordinate with	13 C Lost	
	the next user the loading and		
	unloading of your samples.		





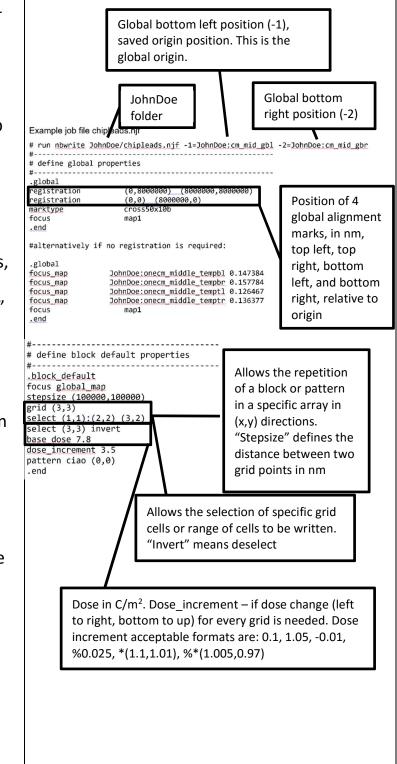
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22. CREATING A JOB FILE: using nB-Write software, a job file consists of several logical section, each starting with a "." Followed by section name, properties line, then ".end". Job files must start with a global section, then optionally block default, then as many block sections as required, then one pattern section for every pattern referenced in the blocks, and finish with a write section. Comments are inserted with "#" at the beginning of the line. 1. .global: contains properties affecting the whole job, such as registration points, mark type, focusing procedure, etc. You can either use a focus map with registration or at certain measured points. 2. .block_default: defines default properties common to all blocks (if not redefined in the .block section). Specifying a property in this section is equivalent to writing the same definition in every block section of the job file. 3. **.block**: here you find the list of patterns to be written together with the optional definition of local registration and mark type. There can be multiple blocks in a job file.



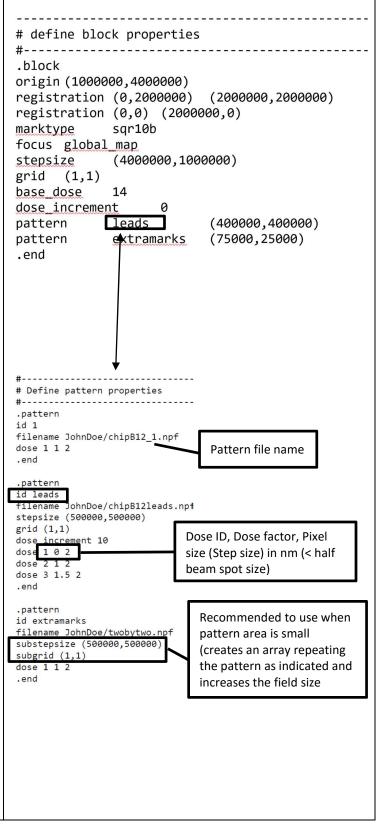




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4. **.pattern**: this section is where the properties of all patterns contained in the job file are defined. A specific block origin can be defined in the ".pattern" section. "id" links the pattern name to be called from the ".block" section. Note that "dose increment" is not possible to use with "subgrid", only with "grid". 5. .write: properties related to the writing, such as what beam current to use. Adding "-r" as a final argument to the run command causes to

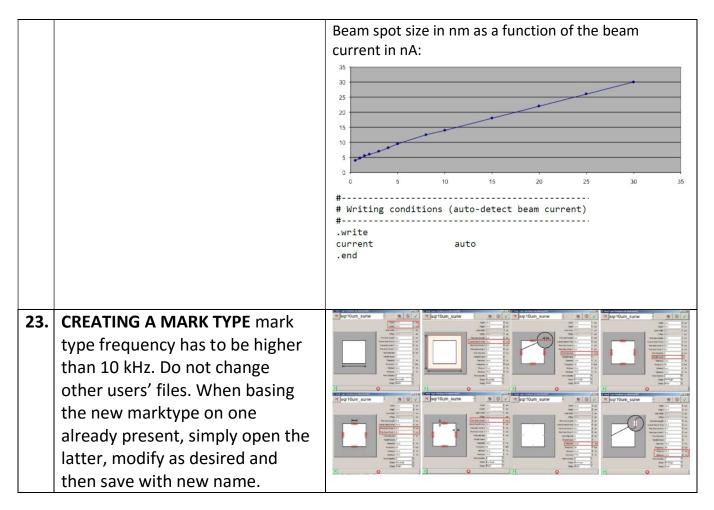
skip the registration for any marks not found.







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24. .GDS FILE CONVERSION: .gds files can be converte

.gds files can be converted to .npf by using the software nbPat. This also can be used to calculate writing time if base dose and beam current are indicated under "beam conditions". Minimum main field (mf) size: 50 μm, minimum subfield (sf) size 5 μm, and maximum clock frequency is 50 MHz. Suggested values are mf=250 µm, sf=10 μm. Under the tab "Pattern" you can view the layout, different layers in different colors, and check the position of main fields and subfields (mouse right button).

SAVE the .npf file, then **RE-OPEN** it and **SAVE AGAIN**, in order to avoid possible fracturing bugs.

File Pattern	gf - nbPat 2-35					-02							
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and the second second							1						
Bottom:	-11.5um			🖪 dry_n	nask.npf								
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Dimension:	500um												
SubField				1									
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Beam Conditions													
Base Dose:	1.000												
Beam Current:	3.000												
Expose Time:	0.030s												
Total Time:	0.141s												
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